



4-27-2015

## Al (confocal) deposition rate 1 using Explorer14 magnetron sputterer

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### Keywords

Explorer14 aluminum deposition rate

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# Al (confocal) deposition rate 1 using Explorer14 magnetron sputterer (Graduate Student Fellow Program)

prepared by Swapil Paliwal (4/2/2014)

- Thickness measurement: P7 stylus profiler
- Deposition rate: 37.5 nm/min at 450 W DC

